



Neck & Décoletage Cream

Formulation Reference: FM00270/A

Formulated to soften, moisturise and rejuvenate the delicate neck area, this cream contains nourishing cold pressed **Texiterra Kalahari Melon Seed oil**, known for its anti-ageing properties and stimulating collagen production helping to promote a more youthful complexion. Contains a rich source of Vitamin E which helps fight premature aging. **Texiterra Cocoa Butter Crystals** in combination with avocado butter work to smooth and nourish the skin, while **Texiterra Raspberry Seed Oil** boosts radiance thanks to its abundance of fatty acids. With light natural emollient **Texique Lux5** to leave skin feeling silky smooth and natural based **Texique HE50** as a co-emulsifier.

Phase	Ingredients	Function	% w/w	Trade Name
A	Aqua	Solvent	6.00	Deionised Water
	Hydroxypropyl Methylcellulose (and) Pullulan (and) Porphyridium Cruentum Extract	Lifting Active Ingredient	0.50	Liftonin Xpress ¹
B	Aqua	Solvent	Up to 100%	Deionised Water
	Disodium EDTA	Chelating Agent	0.05	Dissolvine NA2 ²
	Citric Acid	pH Adjuster	0.02	Citric Acid ³
C	Glycerin	Humectant	3.00	Vegetable Glycerine ⁴
D	C13-15 Alkane (and) Caprylic/Capric Triglyceride	Natural Emollient	3.00	Texique Lux 5 ⁵
	Citrillus lanatus (Watermelon Seed) Oil	Natural Oil/Softening	2.50	Texiterra Kalahari Melon Seed Oil ⁵
	Rubus Idaeus Seed Oil	Natural Oil/Softening	0.50	Texiterra Cold Pressed Raspberry Seed Oil ⁵
	Theobroma Cacao Seed Butter	Butter/Moisturising	2.00	Texiterra Cocoa Butter Crystals ⁵
	Persea Gratissima Oil (and) Hydrogenated Vegetable Oil (and) Tocopherol	Butter/Moisturising	2.00	Avocado Butter ³
	Cetearyl Alcohol	Wax	2.00	Lanette 1665 ⁶
	Cetearyl Oliviate (and) Sorbitan Oliviate	Emulsifier	2.00	Olivem 1000 ⁷
	Tocopheryl Acetate	Antioxidant	0.20	Q-VIT-E ⁸
E	Silicon Dioxide	Soft Focus Effect	0.20	Silica Microsphere ⁹



	Hydrated Silica	Oil Absorption	0.30	Silica Microfine ¹⁰
	CI 77891 (and) Mica (and) Silica (and) Alumina	Mica	0.20	Ronaflair Softshade ¹¹
F	Acrylates/acrylamide copolymer (and) C13-15 Alkane (and) Trideceth-7	Thickener/ Emulsifier / Rheology Modifier	3.00	Texique HE50 ⁵
G	Saccharide Isomerate	Moisturising	1.00	Pentavitin ¹²
	Phenoxyethanol (and) Caprylyl Glycol (and) Sorbic Acid	Preservative	1.00	Optiphen Plus ¹³
	Parfum	Perfume	QS	

Suppliers: | ¹ Rahn AG | ² Nouryon | ³ The Soapery | ⁴ Special Ingredients | ⁵ **Scott Bader** | ⁶ BASF | ⁷ Hallstar | ⁸ OQEMA | ⁹ Micamoma |
| ¹⁰ Aromatic Online | ¹¹ Merck | ¹² DSM | ¹³ Ashland |

Preparation procedure

1. Weigh out Phase A and allow to fully hydrate whilst gently stirring on a magnetic stirrer plate.
2. Weigh out Phase B water into the main vessel and add remaining Phase B individually with mixing between additions until completely dissolved.
3. Add Phase C to main vessel and mix until uniform. Start heating to 70°C.
4. In a separate vessel add Phase D and start heating to 70°C.
5. At temperature add Phase E into Phase D and mix until uniform.
6. Maintain temperature at circa 70°C and add stage 5 pre-mix into the main batch and homogenise until smooth and uniform.
7. At 60°C add Phase F into the main batch and homogenise until smooth and uniform.
8. Cool down to below 40°C with gentle mixing.
9. At below 40°C add Phase G and Phase A into the main batch individually with mixing between additions.
10. Adjust pH to 5.00 to 6.00.

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